

Highly dispersed PTFE/Co₃O₄ flexible films as photocatalyst showing fast kinetic performance for the discoloration of azo-dyes under solar irradiation

P. Raja^a, M. Bensimon^b, U. Klehm^c, P. Albers^c, D. Laub^d,
L. Kiwi-Minsker^a, A. Renken^a, J. Kiwi^{a,*}

^a Institute of Chemical Sciences and Engineering, LGRC, Laboratory of Photonics and Interface, Station 6, 1015 Lausanne, Switzerland

^b EPFL, ENAC, ICARE, GEOLEP, Station 18, 1015 Lausanne, Switzerland

^c AQura GmbH, Wolfgang, Rodenbacher Chaussee 4, D-63457 Hanau, Germany

^d Interdepartamental Institute of Electron Microscopy (CIME), Station 12, EPFL, 1015 Lausanne, Switzerland

Received 5 July 2006; received in revised form 23 October 2006; accepted 28 October 2006

Available online 28 November 2006

Abstract

Small nanosized clusters of Co₃O₄ coated on PTFE (polytetrafluoroethylene) flexible film is reported as a novel supported photocatalyst effective in the fast discoloration of the azo-dye Orange II under simulated solar radiation in the presence of oxone (2KHSO₅·KHSO₄·K₂SO₄). The photocatalytic discoloration of Orange II on the PTFE/Co₃O₄ films proceeds within minutes and the process could be repeated many times without a loss in photocatalyst stability. The photodiscoloration proceeds with a photonic efficiency of ~1. The PTFE seems to act as a structure forming matrix for the colloidal Co₃O₄ coated on its surface leading to nanosized clusters of Co₃O₄. Monitoring the amount of Co²⁺-ions shows the Co²⁺-ions from the PTFE/Co₃O₄ during the photocatalysis enter the solution and at a later stage re-adsorb on the Co₃O₄ crystallographic network (~8 min). By elemental analysis (EA) the loading of Co-loading per cm² PTFE film was found to vary between 1% and 2%. Transmission electron microscopy (TEM) shows the size of the Co₃O₄ clusters to vary between 3 and 10 nm. Electron dispersive spectrometry (EDS) confirms the presence of Co on the PTFE. X-ray photoelectron spectroscopy (XPS) of the PTFE/Co₃O₄ films reveal a partial reduction of the Co₃O₄ after Orange II discoloration leading to a substantial increase of the amount of Co(II) species in the Co₃O₄. Physical insight is provided into the catalyst film surface by carrying out Ar-sputtering of the PTFE/Co₃O₄ surface to remove the catalyst overlayers up to ~20 nm.

© 2006 Elsevier B.V. All rights reserved.

Keywords: Photocatalyst; PTFE–Co-oxide; XPS; Azo-dye

1. Introduction

The abatement of organic pollutants and dyes in water bodies, industrial sites and furtive emissions by Advanced Oxidation Technologies has become a topic of growing interest and concern during the last 15 years [1,2]. Oxone is an oxidant widely used in the degradation of pollutants in the dark and under light radiation [3]. The redox potential of the oxosulfo-radicals generated by oxone (HSO₅^{•-} in net sense) of 1.82 eV [4–7] is higher than the potential of the OH[•] radicals generated by H₂O₂ of

1.76 eV [8]. The accelerated decomposition of oxone in homogeneous solution in the presence of Fe, Cu and Mn-ions has been recently reported [9,10]. More recently, the kinetics of azo-dye decomposition was shown to be drastically accelerated when Co²⁺-ions were used instead of Fe, Cu and Mn to mediate oxone decomposition under light irradiation [11,12].

Oxone/Co²⁺-ions systems to degrade organic pollutants in the dark or under light have revealed to be effective but present the drawbacks of homogeneous systems. A separation of the catalyst from the solution is required at the end of the treatment. This is why we focus the present work on supported photocatalysts.

In the present study, we show that the discoloration of Orange II proceeds in the minute range on PTFE/Co₃O₄ films under visible light irradiation. In the last few years we have reported

* Corresponding author.

E-mail address: john.kiwi@epfl.ch (J. Kiwi).

several TiO₂ supported photocatalysts fixed on inert supports able to discolor and degrade azo-dyes. These supported catalysts were: Nafion/TiO₂ [13], glass-fibers/TiO₂ [14], Fussabond/TiO₂ films [15] and the discoloration proceeded only within several hours under light irradiation.

A fast dye discoloration kinetics is an important parameter to address in the field of Advanced Oxidation and since reaction kinetics limits the practical application of most processes in this area. A slow kinetics processes precludes the practical utilization of photocatalysis when it comes to treat sizable amount of industrial effluents. Slow reaction kinetics implies long treating times with the ensuing high amount of costly photons (energy) and increased labor costs.

2. Experimental section

2.1. Reagents and materials

Reagents like acid and bases, organic solvents, the dye (Orange II) and H₂O₂ were pro-analysis (p.a.) from Fluka AG Buchs, Switzerland and used without further purification. Millipore-Q tri-distilled H₂O was used throughout this study. The oxone is potassium peroxymonosulfate [CAS-RN 10058-23-8] which is one component of the triple salt as noted in the Aldrich Cat No. 22803-6. The poly-tetra-fluoro-ethylene (PTFE) was obtained from Longfellow, UK is a polymer film 100 μm thick showing in its structure a recurring monomer unit [CF₂-CF₂]_n. The thermal resistance shows a PTFE film with a fusion point at 327 °C, 2 min stability at 320 °C and long-term heat resistance up to 260 °C. Other properties of PTFE are: density 2.2 g/cm³, excellent resistance to UV-light and against acids, bases and organic solvents.

2.2. Catalyst preparation

The films of spinel Co₃O₄ were prepared from Co(II) sulfate hepta-hydrate solution 3 M (842.91 g/l) precipitating the oxide out with a solution KOH 3 M (56.10 g/l). The precipitate was washed with deionized water and re-dispersed (peptized) with concentrated acetic acid. The Co-colloid was deposited on the PTFE film by dip coating and was kept at 4 °C (fridge) for subsequent use [16]. The PTFE film was rinsed with deionized water and then dried at 60 °C. The dried film was dipped into the Co₃O₄ sol. Then, the films were dried at room temperature before heating them at 280 °C for 2 h to form the spinel crystallographic structure and concomitantly diffusing the oxide into the PTFE film. The PTFE/Co₃O₄ film was then let cool to room temperature. The fact that 280 °C was employed a temperature above the fluid temperature limit of PTFE was requires for the adhesion process of the Co₃O₄ to the PTFE surface.

2.3. Irradiation procedures and analyses of the irradiated solutions

The photodegradation of Orange II was carried out in small batch cylindrical photochemical reactors made from Pyrex glass

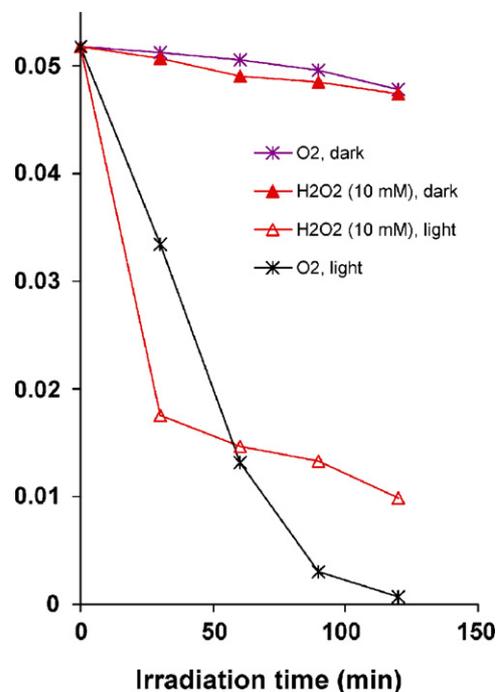


Fig. 1. Dark discoloration and photodiscoloration of diluted Orange II (0.05 mM) in homogeneous solution. Solutions were irradiated in a Suntest solar light simulator (90 mW/cm²) at initial pH 7.

(cut-off $\lambda = 290$ nm) of 70 ml capacity containing 50 ml aqueous solution. The strips 48 cm² films of LDPE-TiO₂ were positioned immediately behind the reactor wall. Irradiation of the samples was carried out in the cavity of a Suntest solar simulator (Hanau, Germany) air cooled at 35 °C. The light intensity in the cavity of the Suntest simulator at tuned at 90 mW/cm² (AM 1) was 2×10^{16} photons/s cm². The Suntest Xe-lamp emitted 7% of the photons in the 290–400 spectral range. The integral radiant flux in the reactor cavity was monitored with a power-meter from YSI Corp., CO, USA. The absorption of the Orange II solutions was followed in a Hewlett-Packard 38620 N-diode array spectrophotometer by the disappearance of the Orange II peak at $\lambda = 486$ nm. Figs. 1–5 report the results for the discoloration runs of Orange II withdrawing a certain portion of the solution (aliquot) at the intervals shown in the x-ordinates (time) in these figures.

2.4. Elemental analysis of the Teflon/Co₃O₄ films

The elemental analysis of the content of Co on the PTFE films before and after the Orange II photocatalytic degradation was carried out by atomic absorption spectrometry using a Perkin-Elmer 300S unit.

2.5. Transmission electron microscopy (TEM)

A field emission TEM microscope Philips EM 430 (300 kV, source LaB₆, resolution 2 Å) was used to measure the particle size of the nanocrystalline Co₃O₄ particles surface. Energy dispersive X-ray spectroscopy (EDS) was used to identify the deposition of Co on the PTFE film. The PTFE film was coated

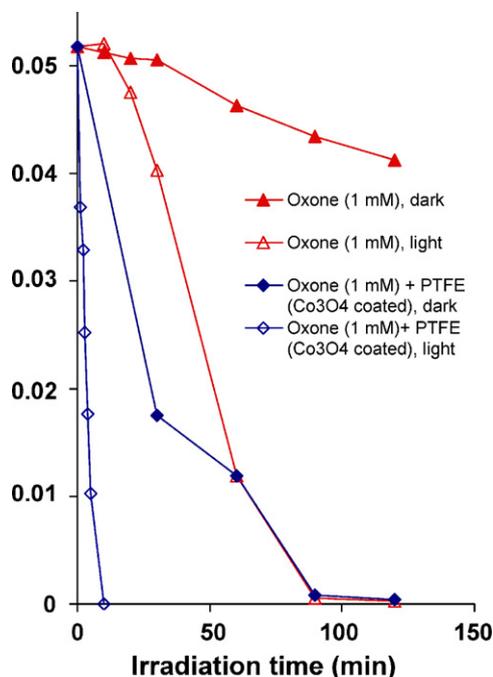


Fig. 2. Dark discoloration and photodiscoloration of Orange II solutions (0.05 mM) in homogeneous and heterogeneous mediated PTFE/Co₃O₄ film in the presence of oxone (1 mM). Solutions were irradiated in a Suntest solar light simulator (90 mW/cm²) at initial pH 7.

with EPON 812 epoxy resin polymerized at 60 °C and then cut with a microtome at room temperature to a thin layer of ~200 nm thickness. Magnification of 10,000× up to 450,000× were used to characterize the samples. The resolution attained was ~0.5 nm.

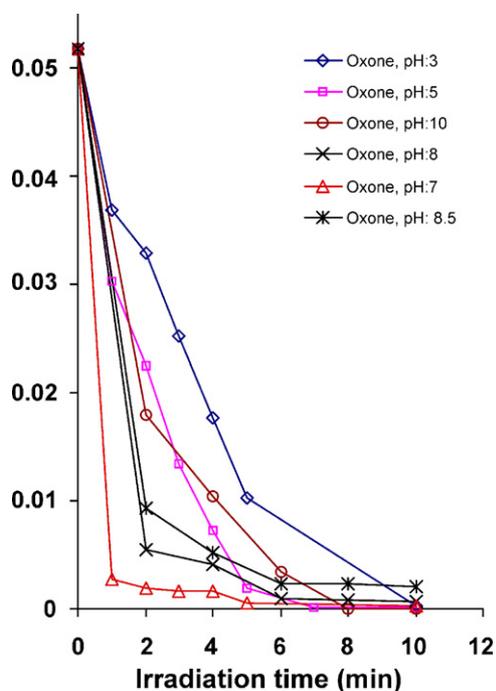


Fig. 3. Photocatalytic discoloration of Orange II (0.05 mM) as a function of the initial pH mediated by PTFE/Co₃O₄ in the presence of oxone (1 mM). Solutions were irradiated in a Suntest solar light simulator (90 mW/cm²).

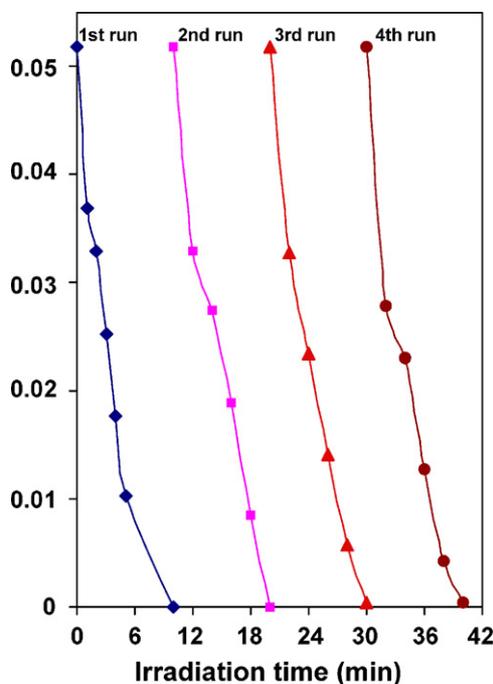


Fig. 4. Repetitive photocatalytic discoloration of Orange II (0.05 mM) mediated by PTFE/Co₃O₄ in the presence of oxone (1 mM). Solutions were irradiated in a Suntest solar light simulator (90 mW/cm²). Initial pH 7.

2.6. X-ray photoelectron spectroscopy (XPS)

The XPS was performed using Mg K α radiation of 150 W. The electron energy analyzer (Leybold EA200) was operated with a band pass energy of 75 eV in the pre-selected transmission mode. The binding energy of the spectrometer was referenced

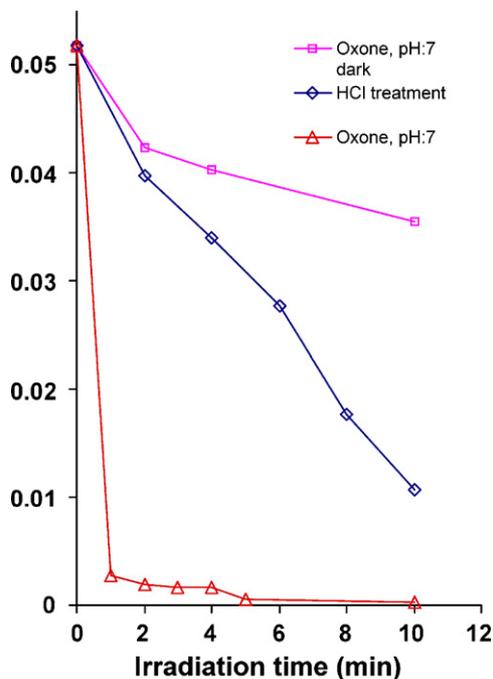


Fig. 5. Dark and photocatalytic discoloration of Orange II (0.05 mM) mediated by PTFE/Co₃O₄ in the presence of oxone (1 mM). Solutions were irradiated in a Suntest solar light simulator (90 mW/cm²). The HCl treatment refers to PTFE/Co₃O₄ films pretreated with 1 M HCl for 1 h.

to 84.0 eV for the Au 4f_{7/2} signal according to the SCA A83 standard of the National Physics Laboratory [17]. The evaluation of the binding energies of the embedded Co-clusters was carried out following the standard procedures. A reproducibility of $\pm 5\%$ was attained in the XPS measurements. The ADS100 set was utilized to evaluate the XPS data by subtraction of X-ray satellites applying the background correction according to Shirley [18]. The presence of electrostatic charging effects was followed by measurements including charge compensation by changing the electrostatic potential at the aperture site of the electron energy analyzer.

2.7. Analysis of the Co²⁺-ions during the photodiscoloration process

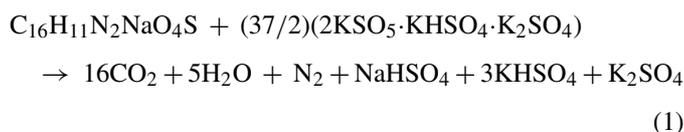
The Co²⁺-ions in solution were quantified by high-resolution inductively coupled plasma spectrometry (ICPS). The samples were acidified with nitric acid and diluted with ultra-pure water. The ion-beam in the plasma unit was directed through the sampling interface and then accelerated into the mass analyzer. The collector system was provided with a Faraday cup for high beam current coupled with an electron-multiplier amplifier for the low intensity signals.

3. Results and discussion

3.1. Homogeneous photocatalytic discoloration of Orange II in homogeneous solution

Fig. 1 shows the dark and light activated photodiscoloration of Orange II. The dark discoloration in the presence of O₂ and H₂O₂ is seen to be negligible. Under solar simulated Suntest light the addition of H₂O₂ (10 mM) leads to a considerable reduction of Orange II, and full discoloration is attained in the case of O₂ purged solutions within 120 min. The O₂ purged solutions seem to produce highly oxidative radicals in solution more effective than H₂O₂. Recently, the details of the oxidation of Orange II in O₂ purged solutions have been investigated [19]. It was reported that H₂O₂ is produced in Orange II/O₂ solutions under light during the decomposition of Orange II. This, in addition to the highly oxidative radicals produced by the O₂ may account for the results obtained in the presence of O₂ in Fig. 1.

Fig. 2 presents the homogeneous photodiscoloration in the dark and under solar simulated irradiation of Orange II diluted solutions and also the photodiscoloration in both cases mediated by PTFE/Co₃O₄ films. The concentration of oxone to be used of 1 mM was estimated from the stoichiometric relation for the degradation of Orange II reported previously using other photocatalysts [9,11,12]:

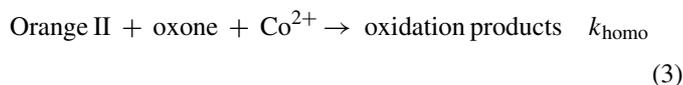
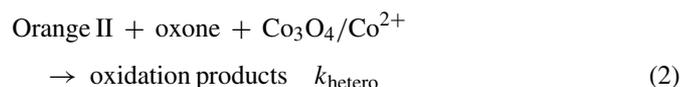


The dark decomposition of oxone by Co²⁺-ions in Fig. 2 was accelerated with respect to the case when oxone was added

alone in the dark and/or under light as previously reported [11,12]. Accelerated photodiscoloration in less than 10 min was observed for Orange II under simulated solar light mediated by PTFE/Co₃O₄ films. The long-lived intermediates of within 10 min of reaction were identified as: oxalic acid, 4-hydroxybenzenesulfonic acid and acetic acid. Within this period, also small amounts of formic and glyoxalic acid were also observed. The measurements of the CO₂ production within 10 min concomitant to the discoloration in Figs. 3–5 indicated a mineralization <20%. No attempt to determine the total mineralization time of Orange II beyond the 10 min reaction was carried out in this study since we focused on the details involving the rapid photodiscoloration process.

3.2. Effect of pH on the photodiscoloration of Orange II homogeneous/heterogeneous reactions and repetitive photodiscoloration of Orange II

Fig. 3 presents the kinetics of Orange II photodiscoloration under solar simulated light mediated by PTFE/Co₃O₄ as function of solution pH. Fig. 3 shows that the photodiscoloration kinetics increases as a function of pH in the sequence 7 > 8 > 8.5 > 5 > 10 > 3. These results suggest a homogeneous–heterogeneous mediated catalysis involving the Co₃O₄ and Co-ions in solution since the Co-ions were observed to precipitate in solution between pH 6.8 and 8.5. Co²⁺-ions available in solution at pH < 6.8 contribute to the oxone decomposition via homogeneous reactions. The competing reactions (2) and (3) are considered to estimate the extend of the homogeneous and heterogeneous reactions:



Since the fastest kinetics in Fig. 3 was observed at initial pH 7, information was sought by induced coupled plasma spectrometry (ICPS) for the amounts of Co²⁺-ions available in solution as a function of time at this pH. The amounts of Co²⁺-ions in solution were: $t=0$, 0.05 ppm; $t=2$ min, 0.6 ppm; $t=4$ min, 0.4 ppm; $t=6$ min, 0.1 ppm; $t=8$ min, 0.05 ppm. The amounts of Co²⁺-ions were observed to increase up to 2 min and decreases afterwards. The Co²⁺ seems therefore to be re-oxidized in solution by the oxone and return to the PTFE/Co₃O₄ film due to two reasons: (a) the overwhelming predominance of the photocatalyst mass present in the solution driving the equilibrium during the photocatalytic process and (b) the predominant crystallographic structure of Co³⁺ in the initial Co₃O₄ that assimilates the Co²⁺ in solution in oxidative media as Co-oxide. This mechanism of ion-release and absorption onto a surface is one of the common routes by which nature mineralize bio-refractory organic contaminants in the natural cycle leading to soil and ground water remediation [20,21]. The amounts found in solution for the Co²⁺-ions suggest a mechanism implying that after Orange II photodiscoloration, these Co-ions go back to the

catalyst surface and would subsequently participate in a new degradation cycle.

Fig. 4 shows the stable nature of the PTFE/Co₃O₄ film during repetitive photodiscoloration runs of Orange II. The release in time of the Co²⁺-ions in solution and subsequent re-adsorption of these ions on the PTFE/Co₃O₄ film explains the stable catalyst performance in Fig. 4. The relative photonic efficiency relates the reactant disappearance (Orange II) to the incident photon flux on the reactor cell walls in a defined time interval. This number allows the standardization of photochemical processes when using different experimental conditions in different laboratories. In Fig. 4, the photonic efficiency (PE) for the photobleaching of Orange II is calculated from the relation:

$$\text{photonic efficiency} = \frac{\text{molecules of Orange II reacted}}{\text{quanta reaching reactor wall}} \quad (4)$$

Taking the Suntest light flux as 1.6 photons/s cm², the solution volume in the reactor as ~50 ml and a cell wall surface of 48.8 cm², the photobleaching of Orange II (0.05 mM) within 10 min proceeds with a photonic efficiency ~1.

Further evidence for the participation of PTFE/Co₃O₄ film Co-clusters during the photodiscoloration of Orange II is presented in Fig. 5. Photodiscoloration runs of Orange II mediated by oxone 1 mM in the dark and under light are shown in the upper and lower traces of Fig. 5. The middle trace shows the photodiscoloration for a solution of Orange where the catalytic process was mediated by a PTFE/Co₃O₄ film pre-equilibrated during 1 h in 1 M HCl. It is readily seen that the PTFE/Co₃O₄ leached film has a considerably lower catalytic activity compared to the non-leached PTFE/Co₃O₄ film under light. This is due to the solubilization of some of the Co₃O₄ attached clusters.

3.3. Transmission electron microscopy (TEM) of the Co-clusters on PTFE

Fig. 6 presents the TEM clusters of Co₃O₄ with sizes between 3 and 10 nm on the PTFE surface. The distribution of these clusters is seen to be non-uniform and the formation of agglomerates seems to be widespread. The Co₃O₄ attaches on the two sides of the PTFE film. No difference was found in the amount and distribution of the Co₃O₄ clusters in the non-used PTFE/Co₃O₄ film and the same film after the photocatalysis. The cut of the PTFE by cryo ultra-microtomy at temperatures -100 °C does not lead to good results. The PTFE is one of the few plastic films able to conserve some of its ductility at a temperature close to the absolute zero (-269 °C). The compression–expansion during the cutting process induces some movements in the Co₃O₄ particles and the TEM does not allow the accurate determination of the thickness of the Co₃O₄ agglomerates on the PTFE film.

Fig. 7 presents the Co₃O₄ particles and agglomerates on the surface of PTFE close to the epoxy resin coating polymerized at the surface of the PTFE/Co₃O₄ catalyst. This epoxy region is shown in the lower left-hand side of Fig. 7. The epoxy coating is necessary when cutting with the microtome a slice of 200 nm of the PTFE/Co₃O₄ sample.

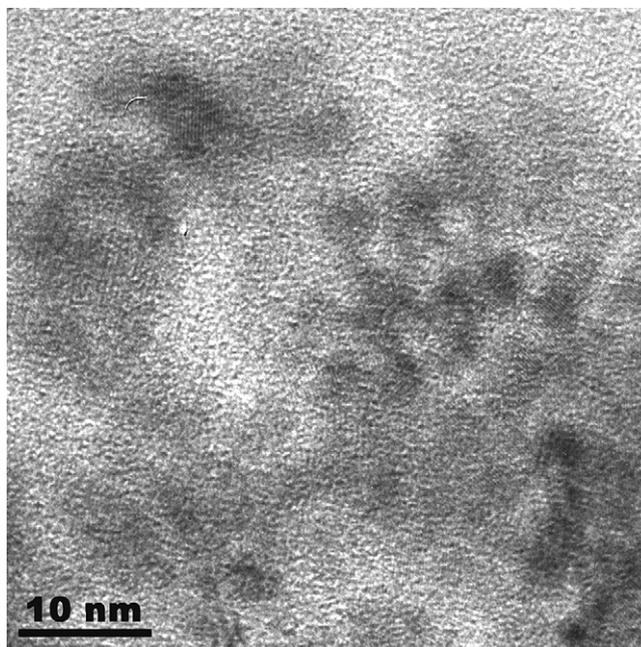


Fig. 6. Transmission electron microscopy (TEM) of the Co₃O₄ particles on the PTFE film showing the Co-oxide agglomerates on the PTFE film.

3.4. X-ray photoelectron spectroscopy (XPS) of PTFE/Co₃O₄ films. Mechanistic considerations

The XPS spectroscopy allows the determination the surface composition of the 2 nm topmost layer and the following composition was found for the surface area occupied by the main elements of the PTFE/Co₃O₄ catalyst: C 1s 15%; O 1s 51.5%; F

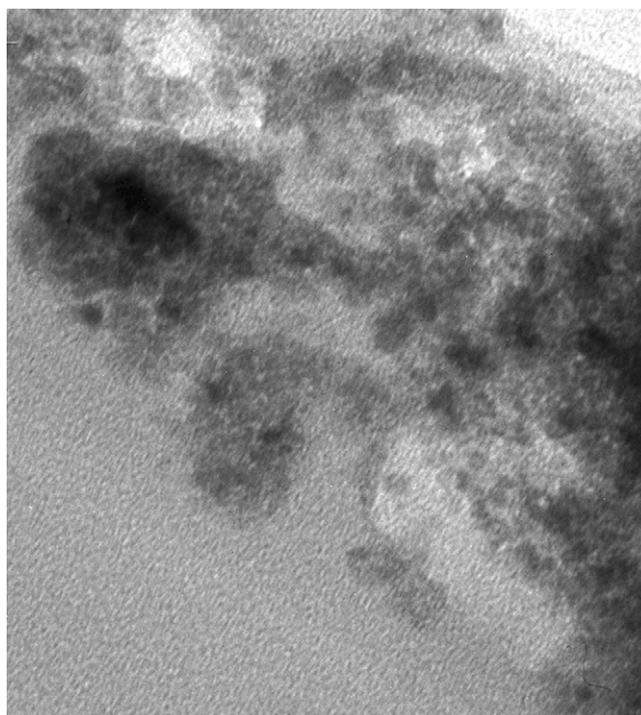


Fig. 7. Co₃O₄ particles on the PTFE film close to the epoxy region after the PTFE film cut by the ultra-microtome.

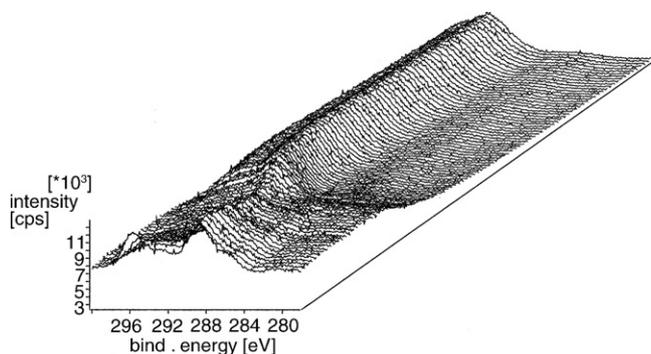


Fig. 8. Depth profile of an Ar sputtered film showing the C-layer distribution in the sub-surface layers.

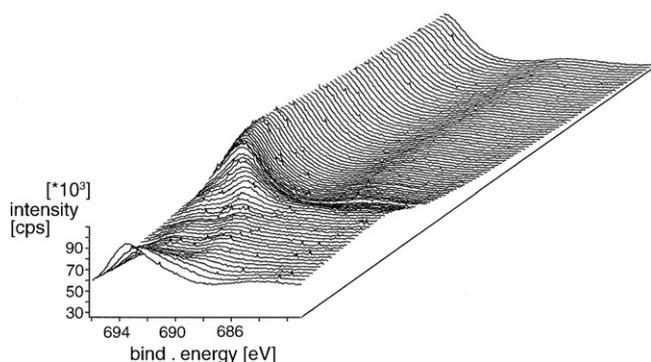


Fig. 9. Depth profile of an Ar sputtered film showing the F-layer distribution in the sub-surface layers.

1s 21.7%; C 11.5%. The composition for the surface area occupied by the main elements of the PTFE alone were: C 1s 21.5%; O 1s 0.25%; F 1s 78.3%.

Fig. 8 shows the PTFE/Co₃O₄ film after erosion of the 100 topmost layers due to the sputtering with 5 keV Ar⁺-ions. Figs. 8–11 show the results of XPS depth profile experiments for the C, F, Co and O atomic layers of the PTFE/Co₃O₄ film. About 100 layers with thickness of ~2 Å each were eroded for each of the elements investigated. The value of 2 Å for the layer thickness is an approximate value since: (a) due to preferential sputtering effects [18] and (b) the layer thickness for each of the elements investigated depends on its particular sensitivity factor [17]. Fig. 8 shows that the C 1s peaks begin to decrease

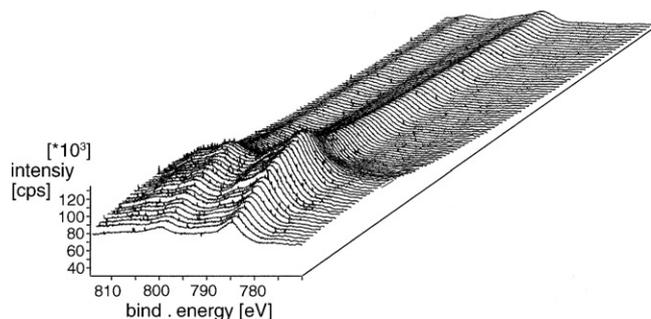


Fig. 10. Depth profile of an Ar sputtered film showing the Co-layer distribution in the sub-surface layers.

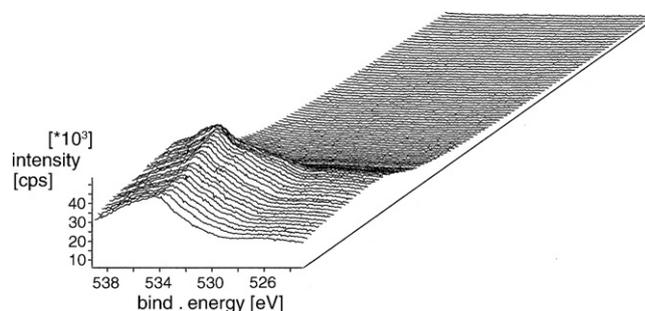
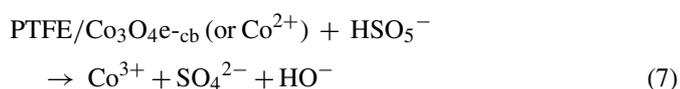
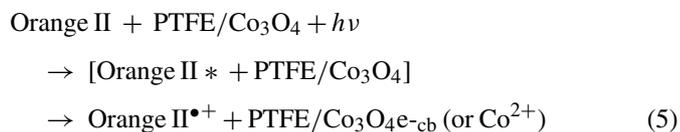


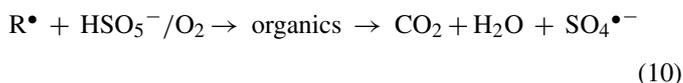
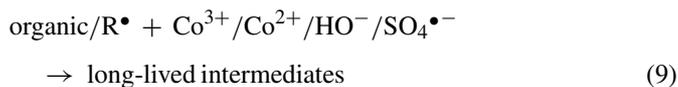
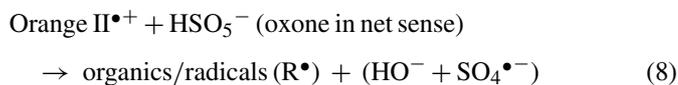
Fig. 11. Depth profile of an Ar sputtered film showing the O-layer distribution in the sub-surface layers.

in the topmost 15 layers close to the catalyst surface due to the Co₃O₄ loading on the PTFE. A small increase of the C 1s peak is noticed in the 5–6 topmost layers due to the atmospheric CO₂ contaminating the catalyst surface.

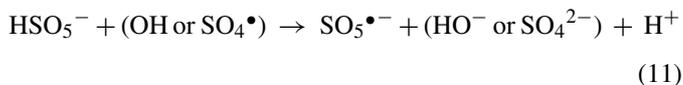
Fig. 9 shows the depth profile of the F topmost layers of PTFE/Co₃O₄ film. The F atomic layers comprising the (CF₂–CF₂)_n units of PTFE begin to decrease about 40 layers or 80 Å below the topmost layer. This is an indication that the Co₃O₄ reaches this depth in the PTFE film. Fig. 10 shows the growth of Co₃O₄ in the topmost 40 layers of the PTFE/Co₃O₄ film as shown by the increase in the doublet Co 2p_{3/2} at 782.3 eV and Co 2p_{3/2ox} at 784.2 eV. Fig. 11 shows the depth profile of the O 1s doublet showing the rich content of the O-atomic layers in the 21–22 topmost catalyst layers. This O 1s signals are associated with the Co₃O₄ deposited in the PTFE film. At the end of the dye photodiscoloration process no S- or N-atoms were detected on the PTFE/Co₃O₄ film. This is indicative of the efficient catalytic nature of the photocatalyst employed that decomposes the Orange II without accumulating decomposition products on its surface.

At time zero the Co in the photocatalyst shows a doublet with Co 2p_{3/2} BE of 782.3 eV (64.2%) and Co 2p_{3/2ox} at 784.2 (45.8%). After the photocatalysis the doublet shows a notable increase for the Co 2p_{3/2} peak shifted to a BE of 781.8 eV. This is the evidence for the increase in the reduced form of Co²⁺-ions after Orange II discoloration. The origin of the of the reduced form of Co²⁺-ions is due to the photosensitization by Orange II of the PTFE/Co₃O₄ film leading to the formation of an azo-dye radical cation [19,22]. A concomitant charge transfer of the electron to the Co₃O₄ layer of the PTFE film occurs as shown in Eq. (7) followed by reactions leading to the dye decomposition in Eqs. (8) and (9) as previously reported in Refs. [11,12]:





With the possible side reactions:



4. Conclusions

An innovative way has been presented to prepare PTFE/Co₃O₄ supported catalyst by a suitable thermal treatment of the PTFE film in contact with the Co₃O₄ colloid. This catalyst allows the accelerated discoloration of Orange II. The nanosized Co₃O₄ clusters observed on PTFE suggests that this inert film is a structure forming agent leading to highly divided clusters of Co₃O₄. The absence of S- and N-atoms on the PTFE/Co₃O₄ film shows the efficient intervention of the photocatalyst in the discoloration process. By XPS Ar-sputtering it is possible to obtain the profile of the C-, O-, Co- and F-components of the 100 topmost PTFE/Co₃O₄ film. The nature of the homogeneous/heterogeneous nature of the photocatalysis is described and a mechanism is suggested for the dye photodiscoloration. The reaction mechanism suggested is consistent with the observed long-range performance of the PTFE/Co₃O₄ catalyst.

Acknowledgment

The COST Action 540 PHONASUM “Photocatalytic technologies and novel nano-surface materials, critical issues” supported this study.

References

- [1] Th. Oppenlaender, Photochemical Purification of Water and Air, Wiley-VCH, Weinheim, Germany, 2003.
- [2] D. Chatterjee, S. Dasgupta, J. Photochem. Photobiol. C: Photochem. Rev. 6 (2005) 186–205.
- [3] A. Mills, S.-K. Lee, J. Photochem. Photobiol. A 152 (2002) 233–247.
- [4] J. Kim, J. Edwards, Inorg. Chim. Acta 235 (1995) 9–21.
- [5] G. Anspitakis, D. Dionysiou, Environ. Sci. Technol. 37 (2003) 4790–4797.
- [6] G. Anspitakis, D. Dionysiou, Appl. Catal. B 54 (2004) 155–163.
- [7] P. Neta, R. Huie, A. Ross, J. Phys. Chem. Ref. Data 17 (1988) 513–586.
- [8] M. Pourbaix, Atlas of Electrochemical Equilibria in Aqueous Solutions, Nace Int., Cebelcor, Brussels, 1974.
- [9] J. Fernandez, P. Maruthamuthu, J. Kiwi, J. Photochem. Photobiol. A 161 (2004) 185–192.
- [10] S. Malato, J. Blanco, C. Richter, B. Braun, M. Maldonado, Appl. Catal. B 17 (1998) 347–355.
- [11] J. Fernandez, V. Nadochenko, J. Kiwi, Chem. Commun. (2003) 2382–2383.
- [12] J. Fernandez, P. Maruthamuthu, A. Renken, J. Kiwi, Appl. Catal. B 49 (2004) 207–215.
- [13] J. Fernandez, J. Bandara, A. Lopez, Ph. Buffat, J. Kiwi, Langmuir 15 (1999) 185–192.
- [14] M. Dhananjeyan, J. Kiwi, P. Albers, O. Enea, Helv. Chim. Acta 84 (2001) 3433–3445.
- [15] M. Dhananjeyan, J. Kiwi, R. Thampi, Chem. Commun. (2000) 1443–1444.
- [16] F. Svegli, B. Orel, I. Grabec-Svegli, V. Kaucic, Electrochim. Acta 45 (2000) 4359–4371.
- [17] D. Briggs, M. Shea, Practical surface analysis Auger and X-ray Photoelectron Spectroscopy, vol. 1, 2nd ed., John Wiley, Chichester, UK, 1990.
- [18] A. Shirley, Phys. Rev. A 179 (B5) (1979) 4709–4716.
- [19] J. Bandara, J. Kiwi, New J. Chem. 23 (1999) 717–724.
- [20] K. Nam, W. Rodriguez, J. Kukor, Chemosphere 45 (2001) 11.
- [21] G. Helz, R. Zepp, D. Crosby, Aquatic and Surface Chemistry, Lewis Pub. Co., Boca Raton, FL, 1994.
- [22] K. Vignodopal, P.V. Kamat, J. Photochem. Photobiol. A 83 (1994) 141–148.